

User Laboratories at the European XFEL

How we can help you getting your sample into the beam

Kristina Lorenzen
Sample Environment and Characterization



XBI User Consortium



Sample Environment and Characterization Group:

Our mission:
Preparation, characterisation
and delivery methods —
creating
sample environments
driving excellent science.

Scope

■ developing new sample environments at all six beamlines

- Jets
- Gases
- Magnetic fields
- Solid support

■ Supporting Users with their sample preparation needs at the European XFEL

- Biological samples
- Chemistry
- Solid samples

■ Running the USER Laboratories

■ Driving science forward

European XFEL User Laboratories – Your Home away from Home



User Laboratories at the European XFEL



- 560 m² biology wet lab
 - Predominantly financed by the XBI user consortium
- 30 m² preparation lab at the SPB/SFX instrument
- 50 m² chemistry labs
- 150 m² physics and microscopy labs



Why do we need a user laboratory?

- Beamtime is precious and expensive, you want the best pre preparation and characterization for your sample
- Ability to adapt quickly and produce more sample/ alter the quality, find and solve problems related to your sample
- XFELs due to their brilliance are able to provide diffraction patterns of much smaller crystals compared to third generation synchrotron sources. The labs on site allow to test your xtals size and properties and jetting before your allocated beamtime.
- Special properties of the beam structure, allowing to monitor fast reactions require special properties during sample preparation (dark, anaerobic...)
- Molecular Movies – small crystals allow for diffusion rates short enough to make kinetic measurements feasible
- Single Particle Imaging - Other high resolution methods like electron microscopy rely on forms of sample fixation and do not image living cells or organisms.

Concept for User Support

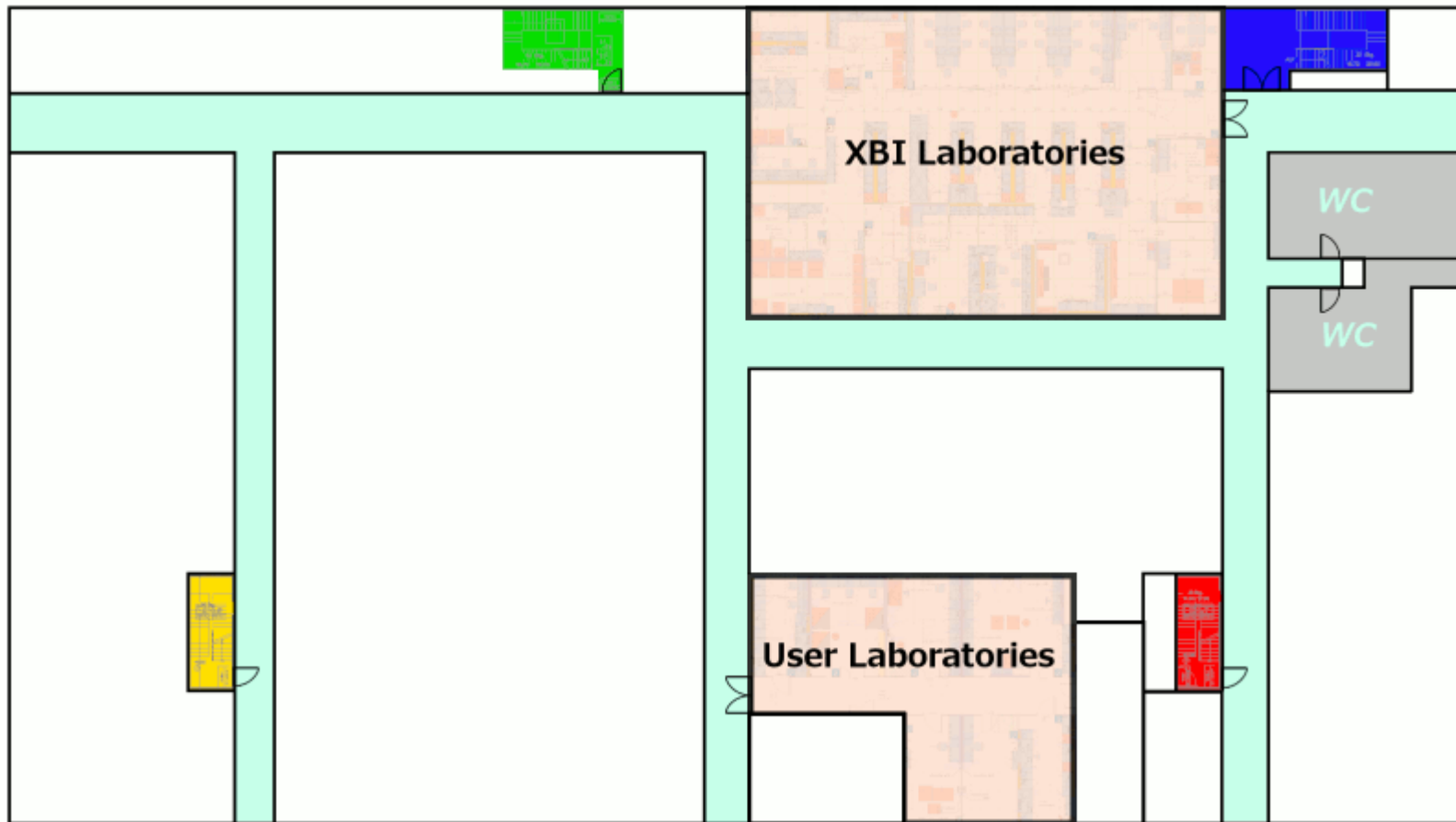
- Bio lab usage is requested in the application for beamtime
- Webpage and Alfresco site (users with xfel.eu account)
 - https://www.xfel.eu/users/experiment_support/user_labs
 - <https://docs.xfel.eu/share/page/site/userlabs/dashboard>
- Three weeks before the users come they need to fill out a “labwork description form”
- The User will have three contacts
 - Local contact
 - Sample contact
 - Lab contact
 - ▶ Does check in and check out with users
 - ▶ Helps to fill out “labwork description form”
- XBI Staff Support
 - Mon - Fri from 9am till 6pm
 - Users are allowed to work outside these hours
 - OnCallDuty (contacted by beamline scientist)

How to contact us

Sample.environment@xfel.eu

User Laboratories

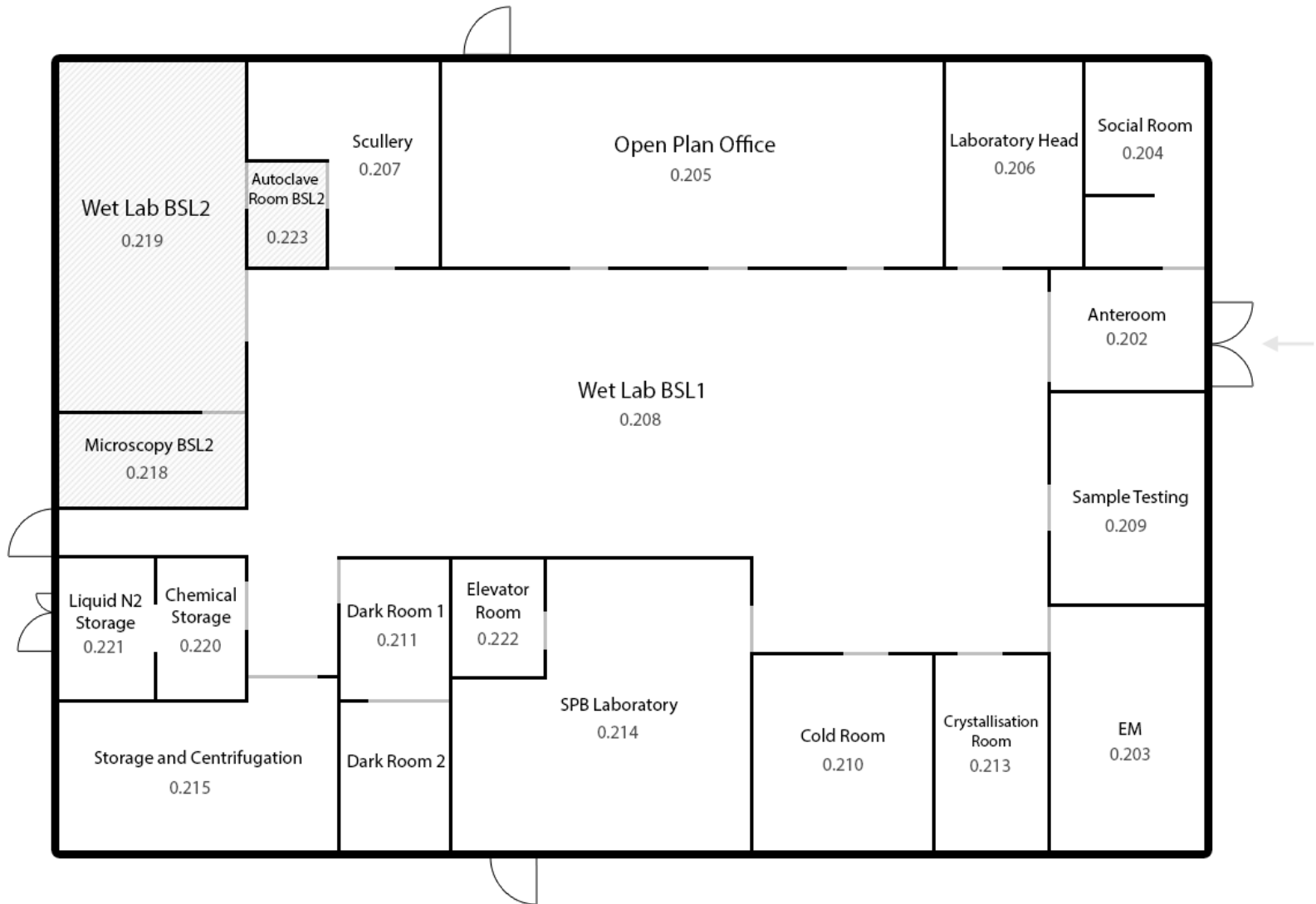
Bio/Chemistry Laboratory Side entrance



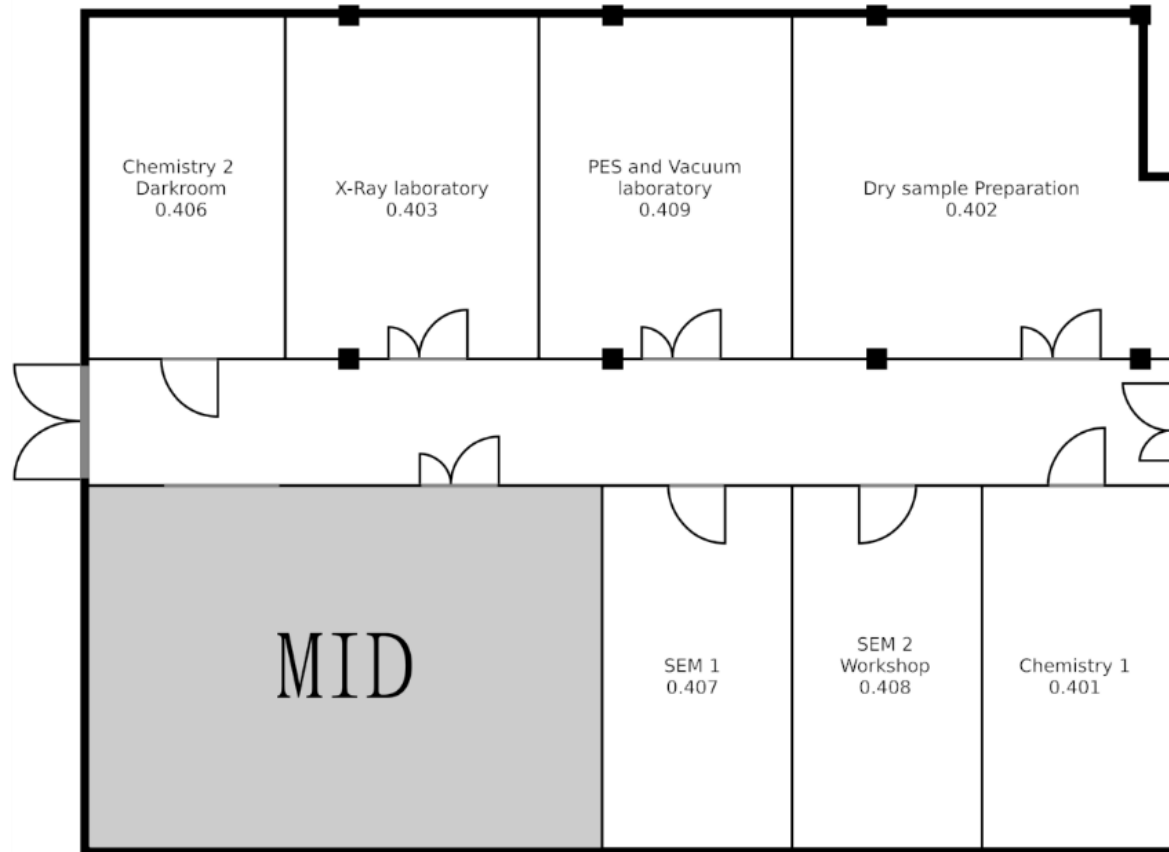
**Building
Front**

Chemistry and Physics Laboratory

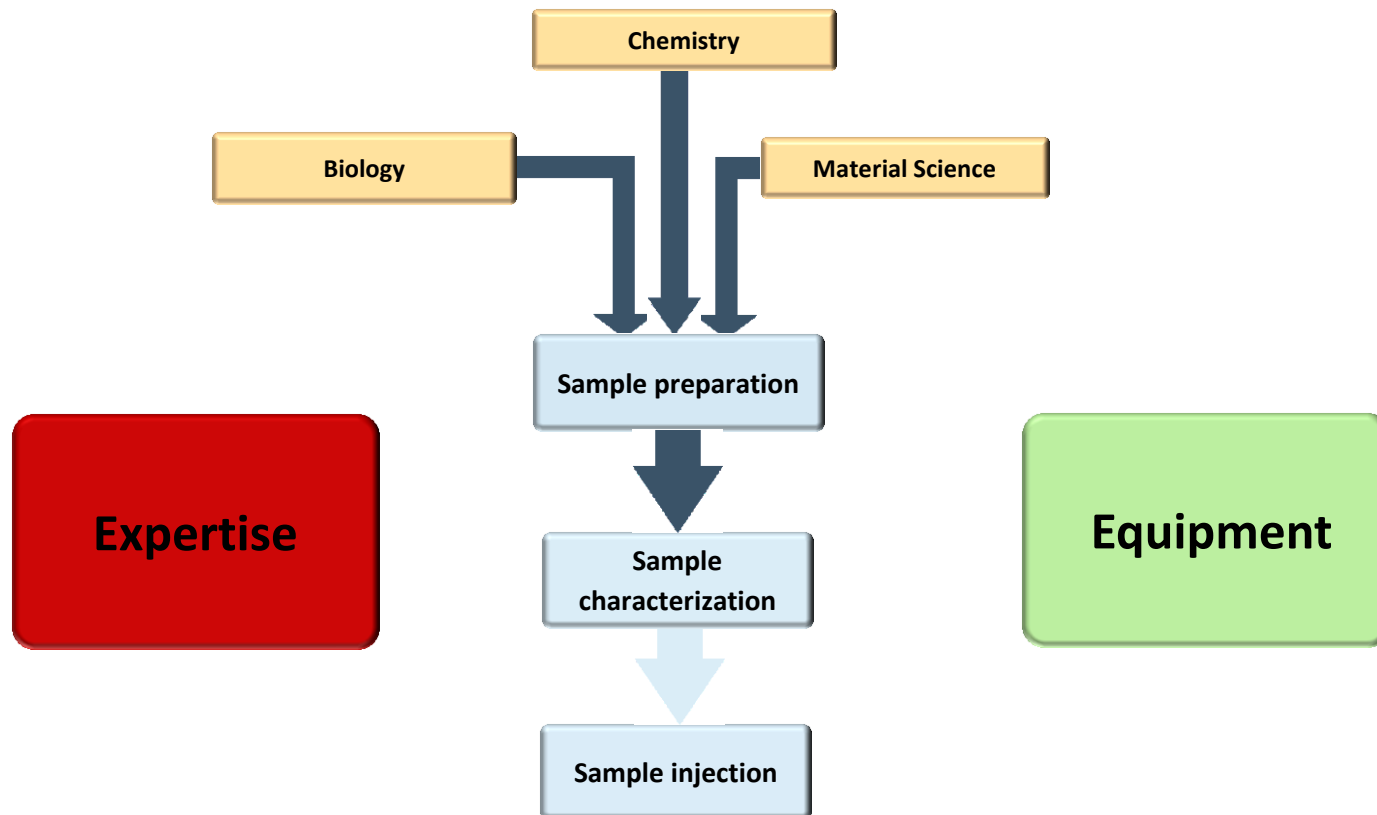
Biological Labs



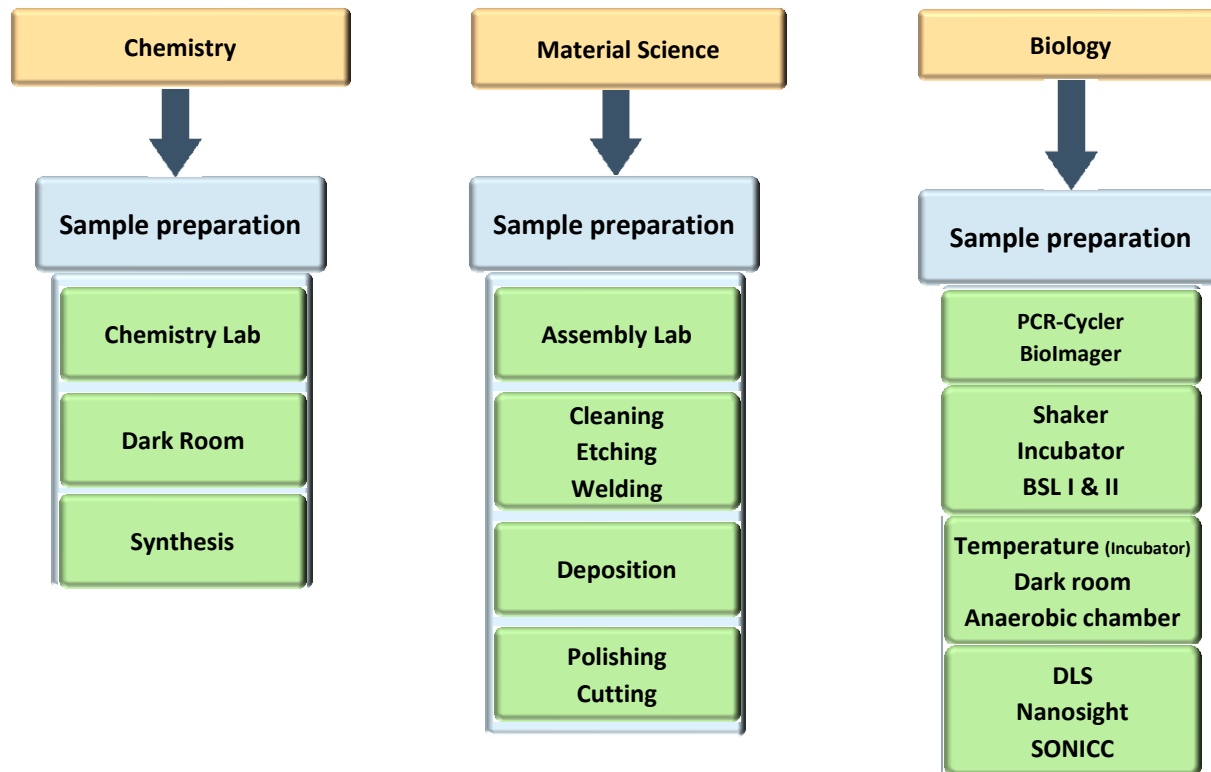
Chemistry and Physics Laboratories



How we can help you getting your sample into the beam



Sample Preparation

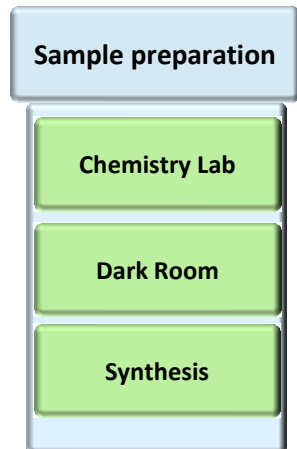


Expertise - Chemistry



Vasilii Bazhenov

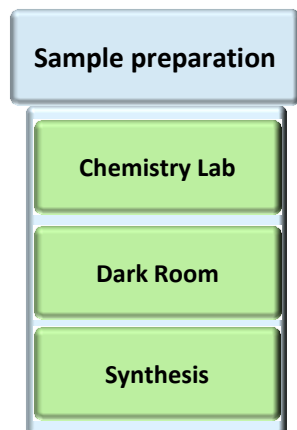
Sample Preparation - Chemistry



- Wet Lab
 - Fumehood
 - Stirrer
 - Shaker
 - Heating Plate



Sample Preparation - Chemistry



Wet Lab

- Bench space
- Fumehood
- Stirrer
- Shaker
- Heating Plate

Fume Hood

- Schlenk Line
- Rotary Evaporator (including Vacuum Pump)



Expertise – Material Science



Carsten Deiter

James Moore

Manuel Izquierdo

Sample Preparation - Material Science/ Solid Samples

Sample preparation

Assembly Lab

Cleaning
Etching
Welding

Deposition

Polishing
Cutting

■ Assembly Lab

■ Tools

■ Laminar Flow Clean Tent

■ Optics

Material Science/ Solid Samples

Sample preparation

Assembly Lab

Cleaning
Etching
Welding

Deposition

Polishing
Cutting

■ Spinncoater

- thin film sample deposition
- Up to 6" (150mm) Ø Wafers
- Up to 4" x 4" (100mm) Substrates
- Speed range: 1-12.000 RPM (± 0.1 RPM)



Material Science/ Solid Samples

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■ Vacuum Oven

- w/wo inert gas
- Up to 200°C
- Ex-proof models for safe drying of samples containing flammable solvents



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■ Plasma Cleaner

- removal of impurities and contaminants



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■ Plasma Cleaner

- removal of impurities and contaminants

■ Etching

- Including hydrofluoric acid



Material Science/ Solid Samples

Sample preparation

Assembly Lab

Cleaning
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Welding

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Cutting

FIB

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- Ex-proof models for safe drying of samples containing flammable solvents

■ Plasma Cleaner

- removal of impurities and contaminants

■ Etching

- Including hydrofluoric acid

■ Welding

- Including spot welder

Material Science/ Solid Samples

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Assembly Lab

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Etching
Welding

Deposition

Polishing
Cutting

FIB

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■ Plasma Cleaner

- removal of impurities and contaminants

■ Etching

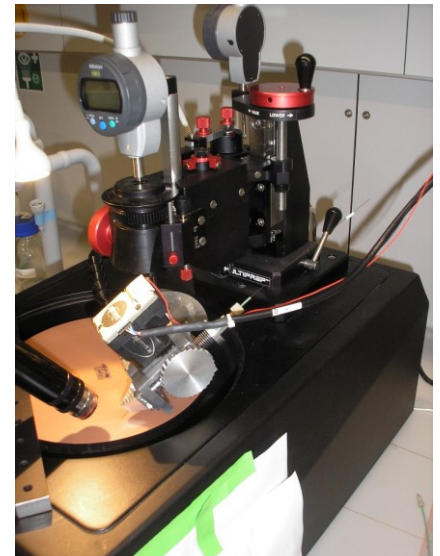
- Including hydrofluoric acid

■ Welding

- Including spot welder

■ Polishing and cutting

- Grinder
- Microtome



Material Science/ Solid Samples

Sample preparation

Assembly Lab

Cleaning
Etching
Welding

Deposition

Polishing
Cutting

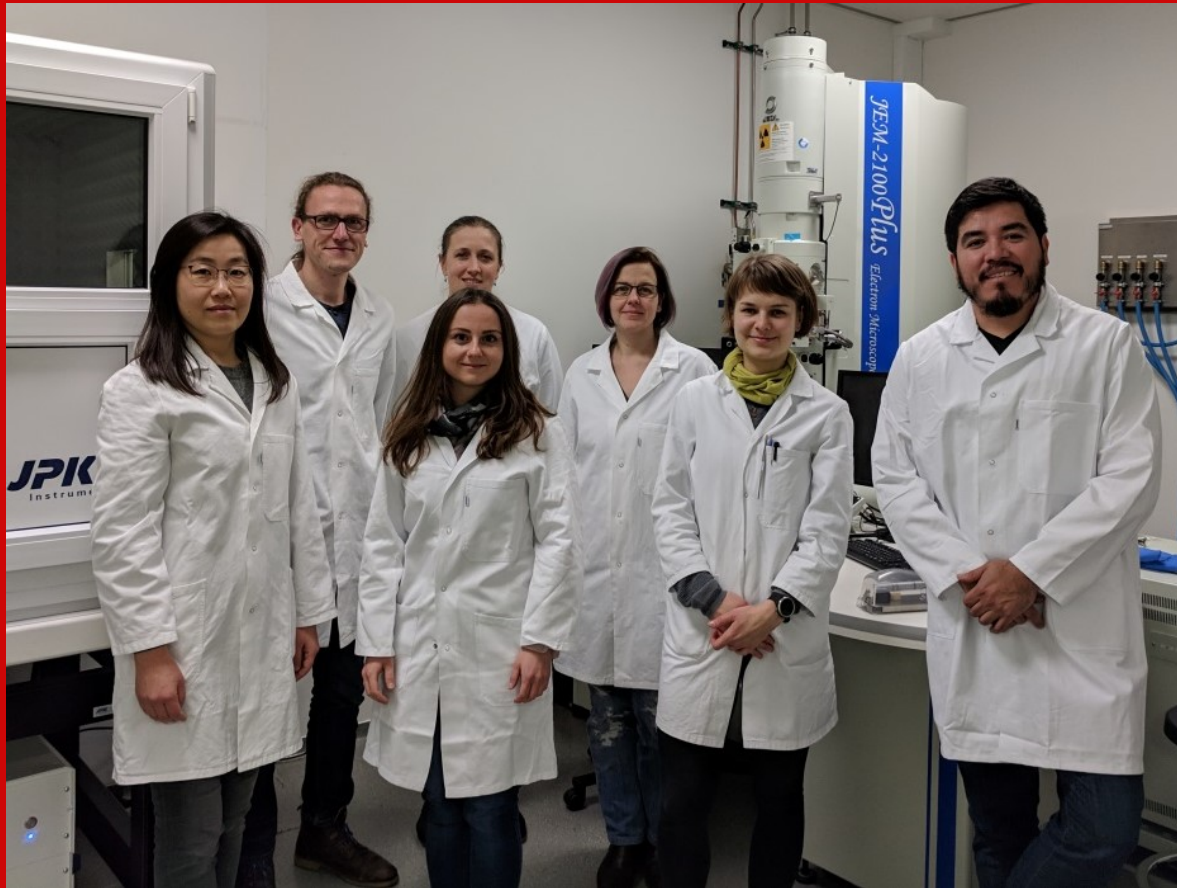
FIB



- Available in late 2019
- TEM lamella preparation
- Nano-patterning via ion-milling
- Pt and C nano-deposition

FEI Helios G4 UC

Expertise - Biological Sample Preparation



Huijong Han
Robin Schubert
Yasmin Gül
Ekaterina Round
Kristina Lorenzen
Jana Makroczyova
Domingo Meza

Biological Sample Preparation

- 3 Microbiological safety cabinets in BSL II , 1 in BSL I
- Type B2



- 2 large shaker and 1 incubator in BSL I and BSL II



- Fermenter
- Infors Labfors 5



Safety cabinets
FACS
BSL I & II

- Insect cell culture

Insect cells

Expression

E. coli

- Bacterial cell culture

Shaker
Incubator
BSL I & II

Large Volume Centrifuge

Sorvall Lynx 6000

Sonicator

Qsonica Q700

Homogenizer

Avestin EmulsiFlex-C3

Chromatography

GE Healthcare Äkta Pure

4 °C and 20 °C

▶ Size exclusion chromatography

▶ Affinity chromatography

• MonoQ/MonoS 5/50 GL

• Superdex 75/100 increase 10/300 GL

• Superdex 75/100 HiLoad 16/600 and Superdex 200 26/600



Ultracentrifuge

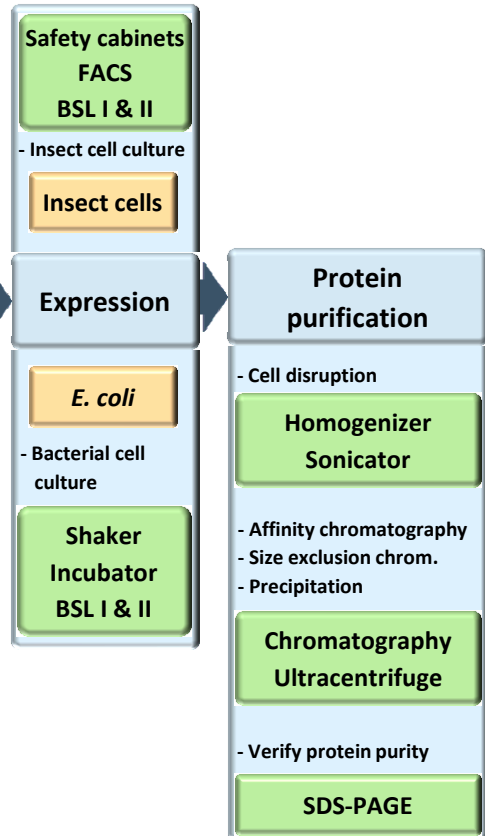
Beckman Coulter Optima XPN-90

Beckman Coulter Optima MAX-XP

▶ Up to 500k g

▶ Fixed angle Typ 45 Ti and Typ 70 Ti

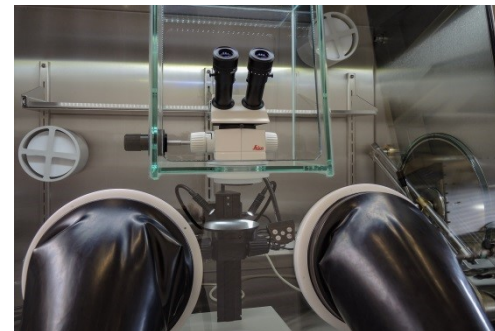
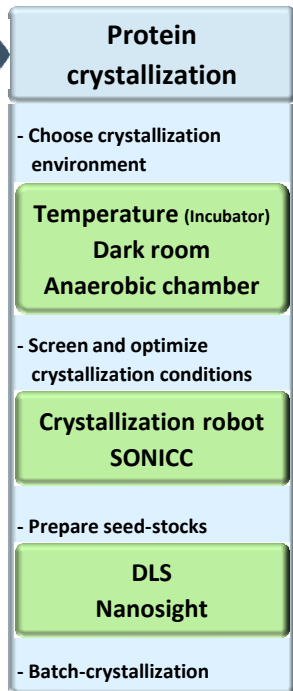
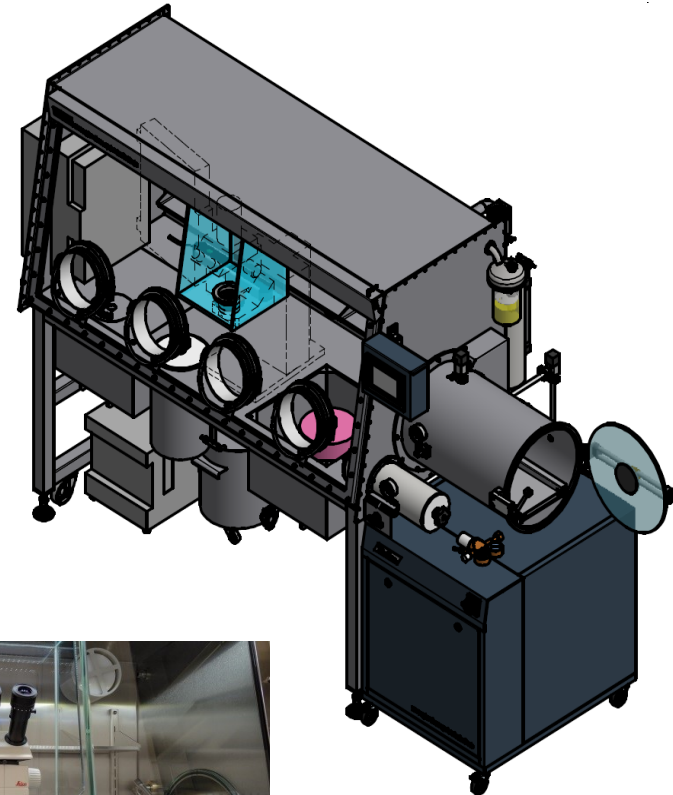
▶ Swinging bucket SW 60 Ti



■ Anaerobic chamber

■ Glovebox Systemtechnik

- ▶ 4-glove glovebox
- ▶ N₂ or Ar, oxygen free atmosphere (<0.5 ppm)
- ▶ Over and underpressure operation
- ▶ 4° C fridge
- ▶ Humidifier
- ▶ Solvent adsorber
- ▶ Microscope in front glass (Leica M205)
- ▶ Flask storage and retractable shelves
- ▶ Spin coater (Polos SPIN150i)



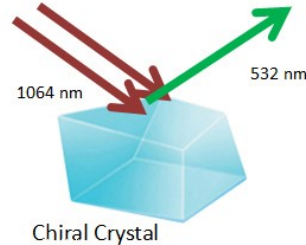
Crystallization robot (coming soon)

- ▶ Small volume pipetting
- ▶ LCP-dispensing

Crystallization incubator

Sanyo

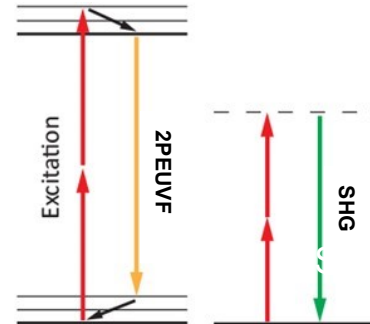
- ▶ 2 incubators
- ▶ 1 incubator in dark room



Crystallization plate imager

Formulatrix SONICC

- ▶ Visible imaging
- ▶ SHG imaging
- ▶ UP-TPEV imaging

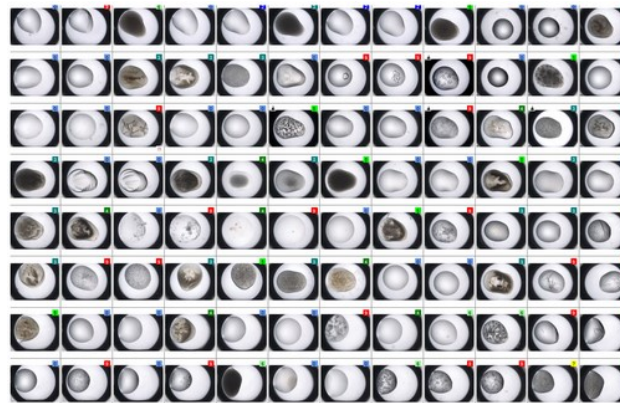


© semrock.com (modified)

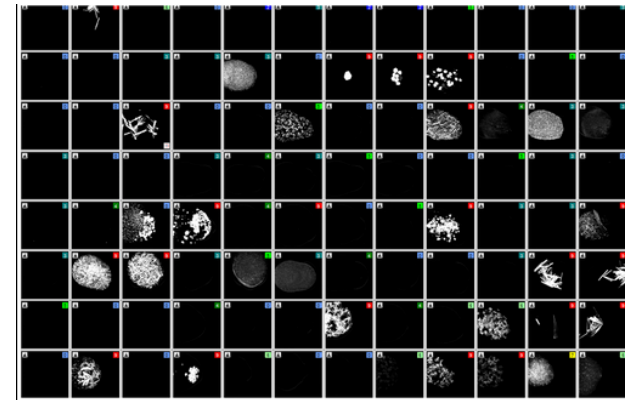
Protein crystallization

- Choose crystallization environment
- Temperature (Incubator)**
Dark room
Anaerobic chamber
- Screen and optimize crystallization conditions
- Crystallization robot**
SONICC
- Prepare seed-stocks
- DLS**
Nanosight
- Batch-crystallization

visible



SHG



Crystallization robot (coming soon)

- ▶ Small volume pipetting
- ▶ LCP-dispensing

Crystallization incubator

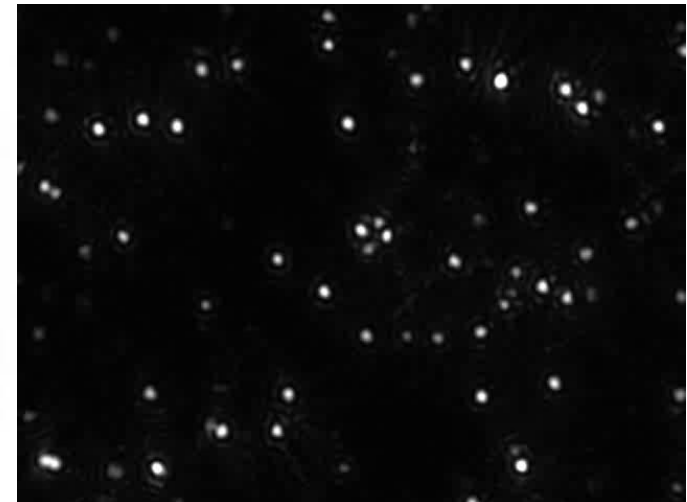
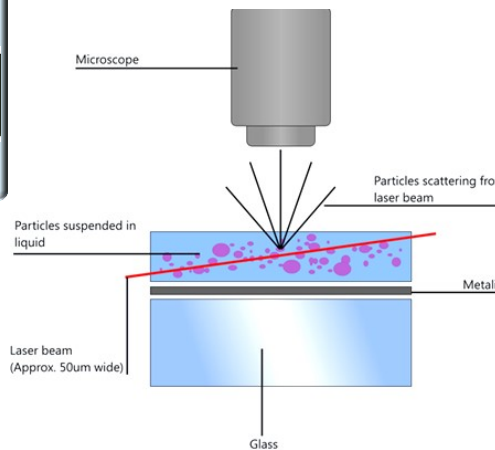
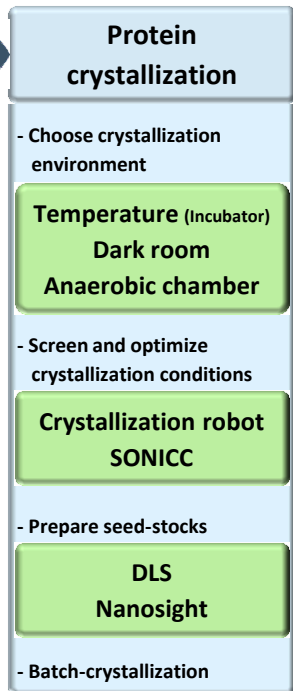
- Sanyo
 - ▶ 2 incubators
 - ▶ 1 incubator in dark room

Single Particle Tracking

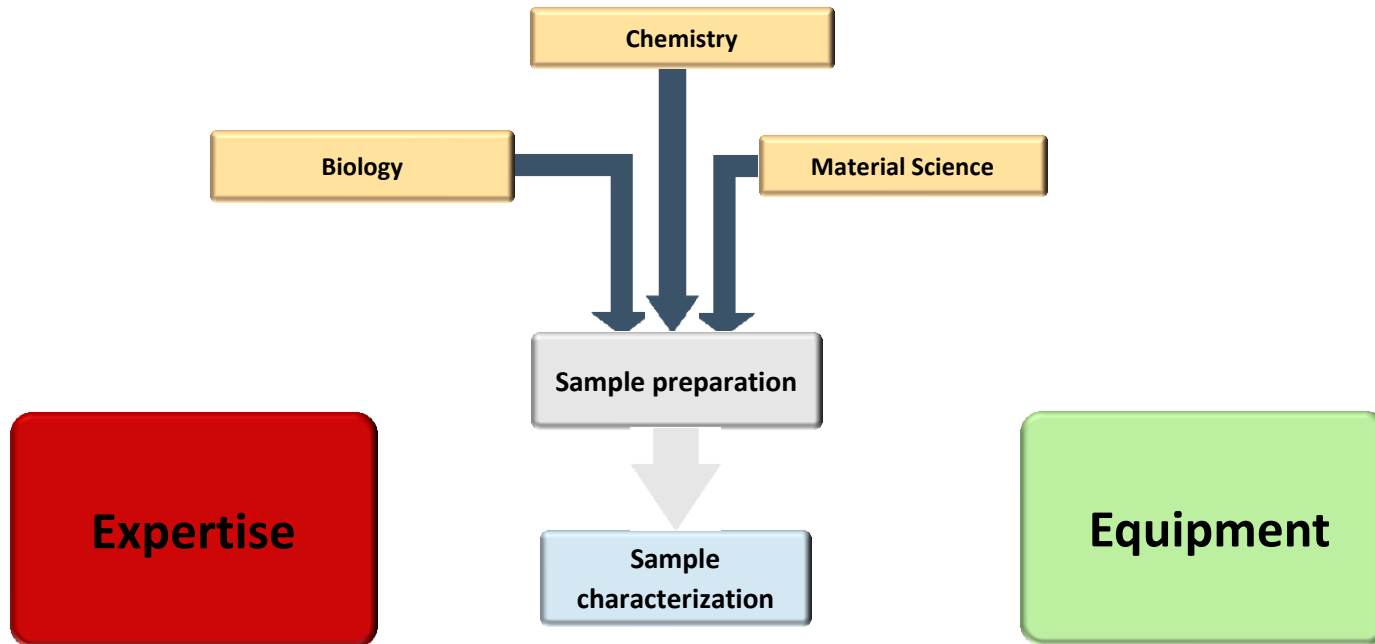
- Malvern NS300 Nanosight
 - ▶ Hydrodynamic radius (20 nm – 2 μm)
 - ▶ Concentration measurements (10⁶ – 10⁹ ml⁻¹)
 - ▶ 480 nm laser

Crystallization plate imager

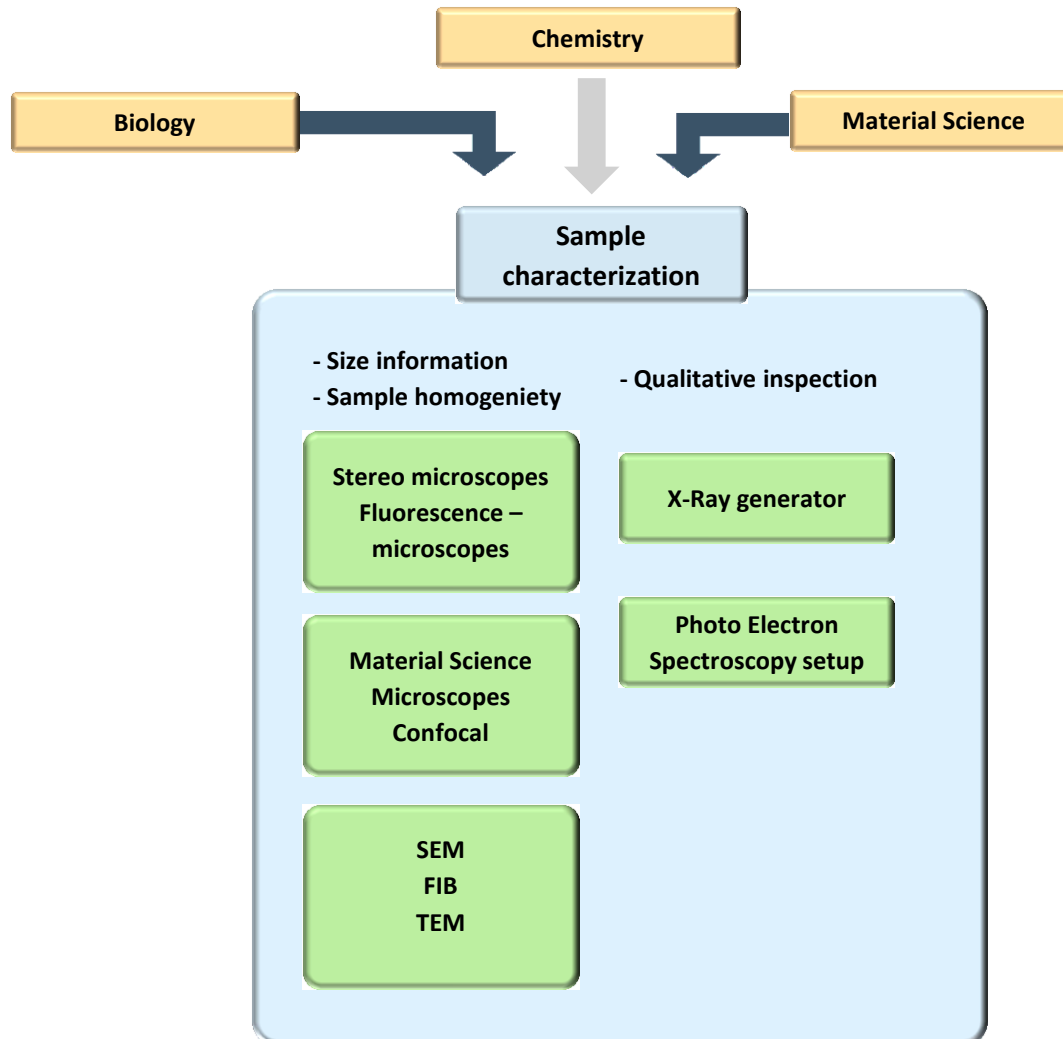
- Formulatrix SONICC
 - ▶ Visible imaging
 - ▶ SHG imaging
 - ▶ UP-TPEV imaging



How we can help you getting your sample into the beam

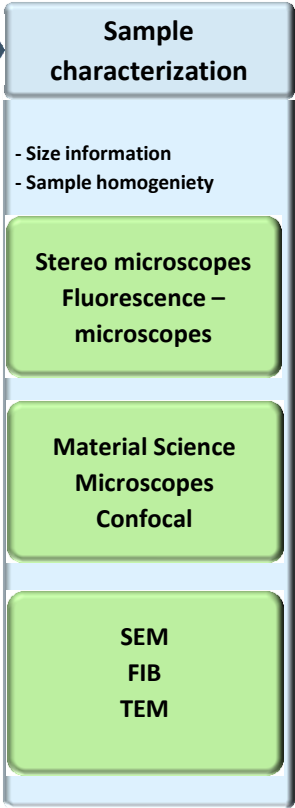


Sample Characterization

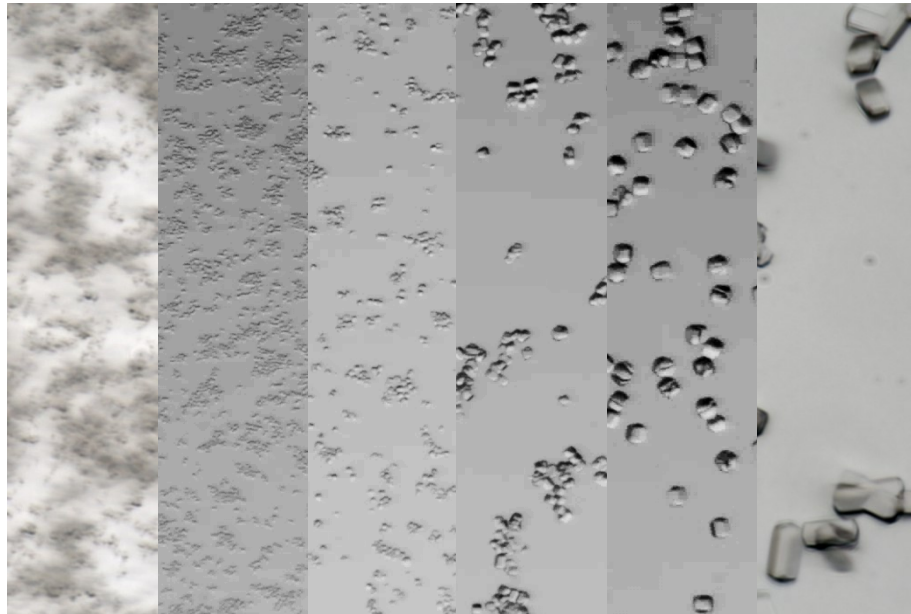


■ **Stereo Microscopes**

- Leica M205 FCA
- Nikon SMZ18
- Olympus SZX16

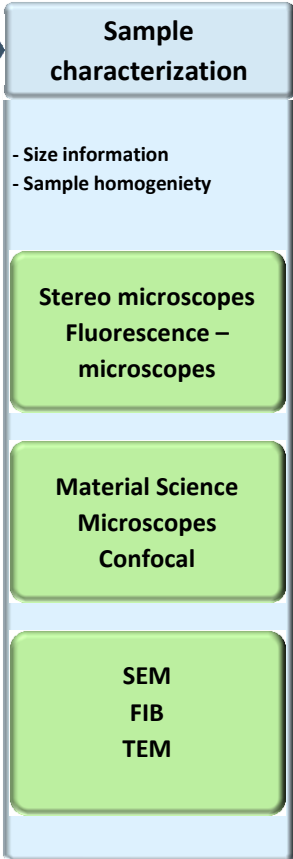
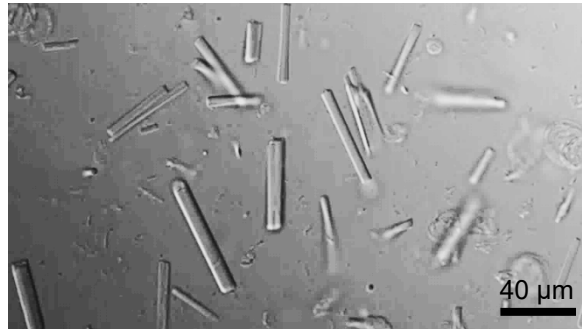


■ **Lysozyme (XBI)**



<1 μm 2 μm 4 μm 8 μm 11 μm 20 μm

PAK4 (Betzel group)



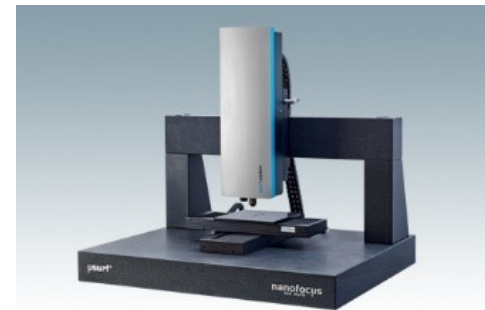
Fluorescence Microscopes

- Nikon Fluorescence NI-E (upright)
- Nikon Fluorescence TI2-E (inverted)



Material Science Microscopes

- Keyence VHX-6000



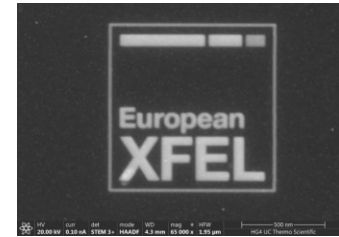
Confocal Microscopes

- Nano Focus Custom

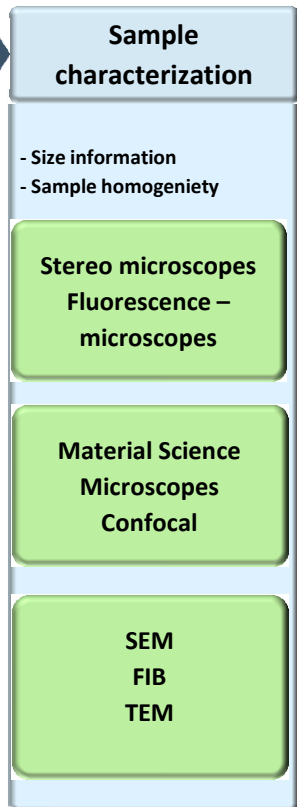
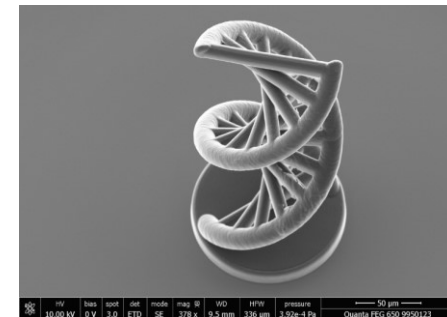
■ Scanning Electron Microscope (SEC lab)

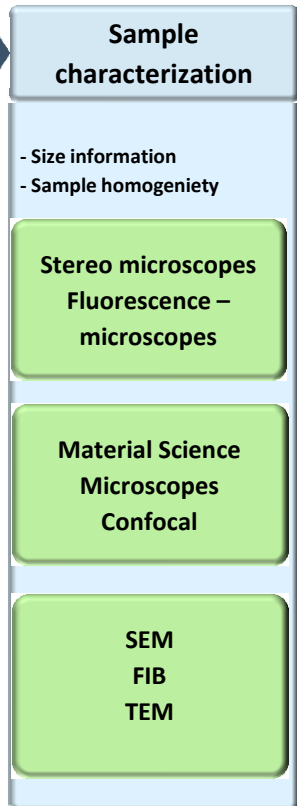
- FEI Quanta FEG 650
 - ▶ SE, BS, ETD
 - ▶ WetSTEM detector
 - ▶ EDS detector
- Leica sputter coater
 - ▶ Carbon, gold, iridium coating
 - ▶ Glow discharging

- STEM image of XFEL logo
 - Platinum deposited on Si₃N₄-membrane



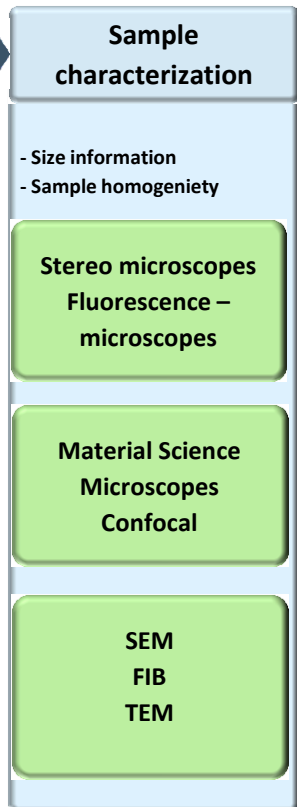
- SEM image of 3D printed structure
 - Aim to print nozzles in photoresin





- STEM imaging of lamellas
- EDS detector

FEI Helios G4 UC



Transmission Electron Microscope

Jeol JEM-2100 Plus

- ▶ 200 keV
- ▶ Cryo pole piece
- ▶ Fishione cryo holder
- ▶ Negative staining with non-radioactive dyes

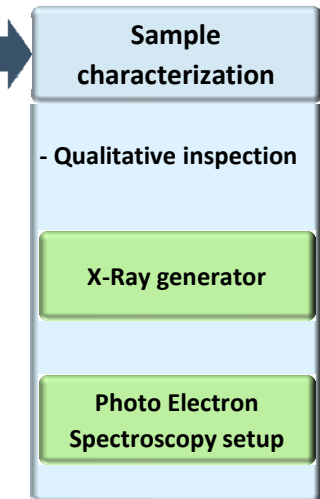
Leica UC7 Ultramicrotome

- ▶ Glass and diamond knife
- ▶ Thin sections down to 50 nm
- ▶ Cutting at RT and cryo conditions

Leica GP2 Cryo plunge freezer

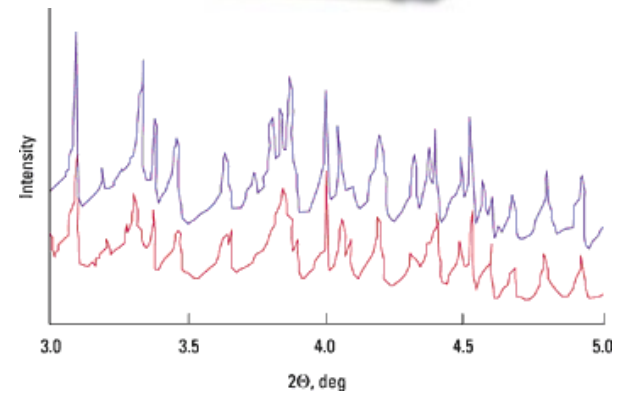
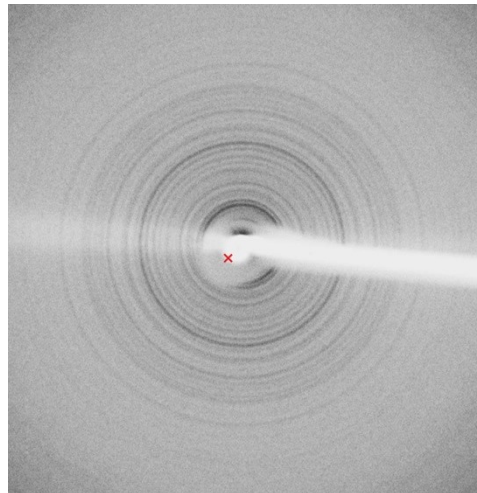
- ▶ Grid freezing in liquid ethene





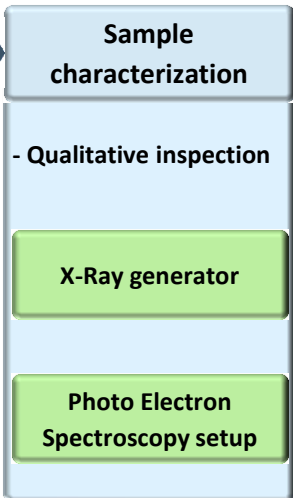
■ X-Ray generator (SEC lab)

- Bruker D8 Advance
 - ▶ Powder diffraction analysis
 - ▶ Obtain 1D diffraction spectrum

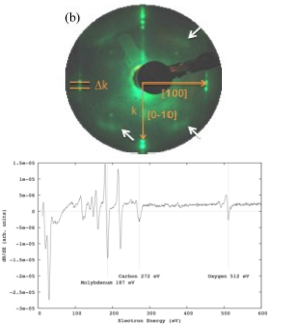
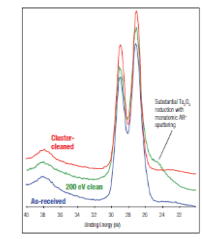
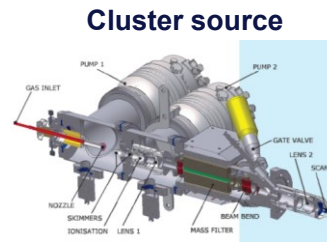
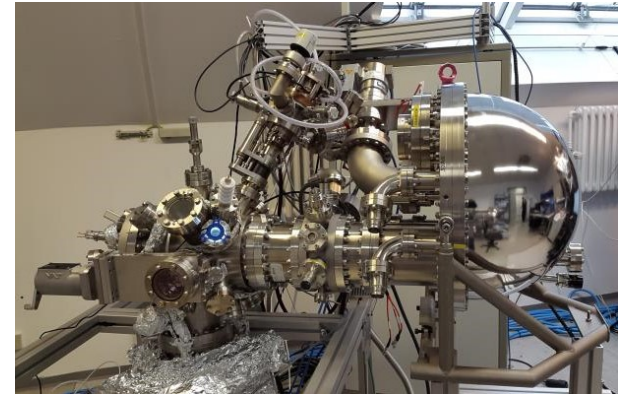


Robert Von Dreele, 2003

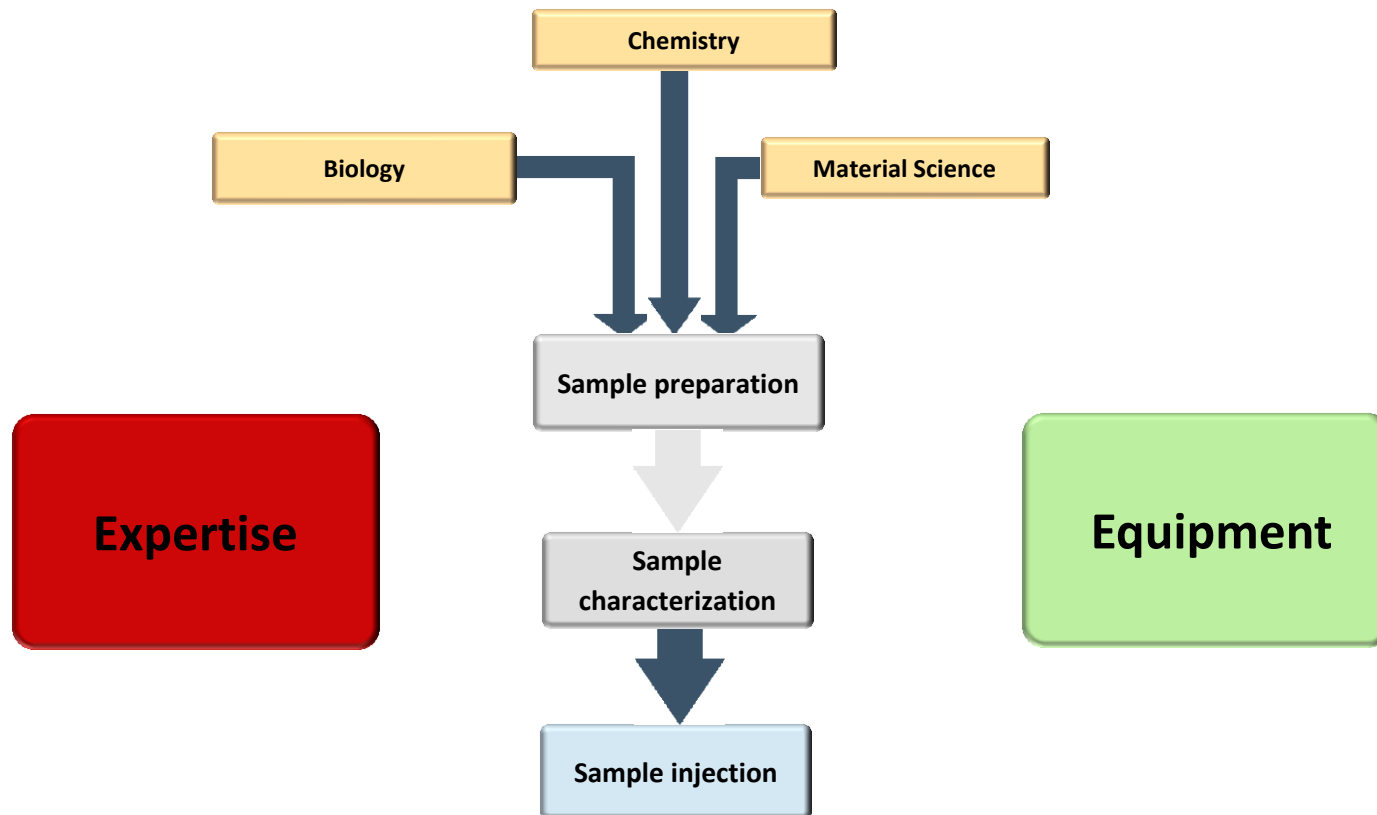
Photoelectron spectrometer



- Electronic structure
 - Band dispersion
 - Fermi surface
- Chemical analysis
 - Alloying
 - Chemical segregation
- Magnetic properties
 - Spin resolved PE
 - MCD/MLD in PE
- Sample characterization
 - Single crystals
 - Thin films
 - Clusters



How we can help you getting your sample into the beam



Expertise – Sample Injection



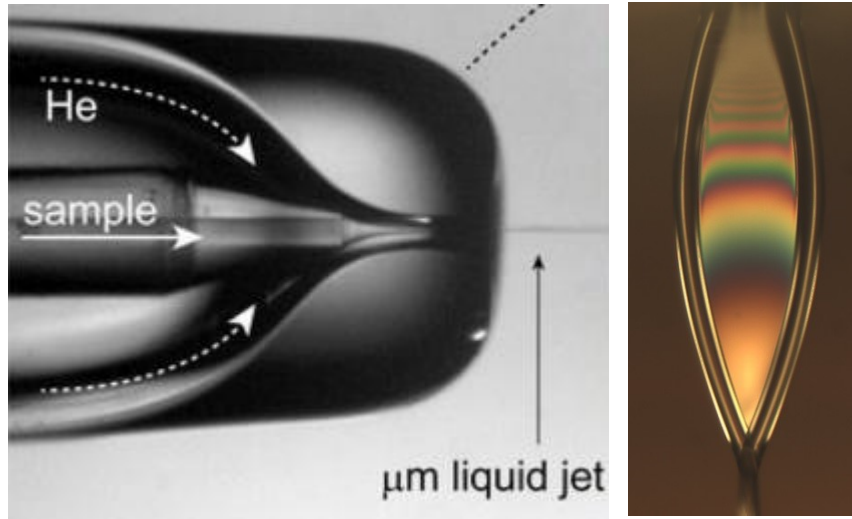
Katerina Dörner

Johan Bielecki

■ Nozzle fabrication

■ GDVN or Microfluidic nozzels, flat sheets, Rayleigh Jets

- ▶ Grinder
- ▶ Plasma cleaner



<https://lcls.slac.stanford.edu/sed/equipment>

Sample injection

- Nozzle assembly
- Rapid prototyping
- Microfluidics

Nozzle fabrication Nano-3D printer

- Test sample injection
- Adjust concentration

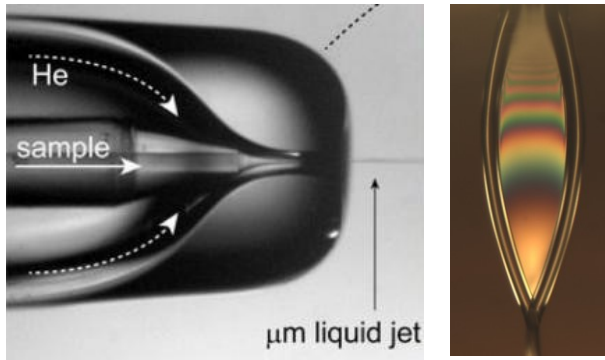
Liquid-jet test-chamber Aerosol-jet test-chamber

Fast Solid Sample Scanner

Magnetic Fields

■ Nozzle fabrication

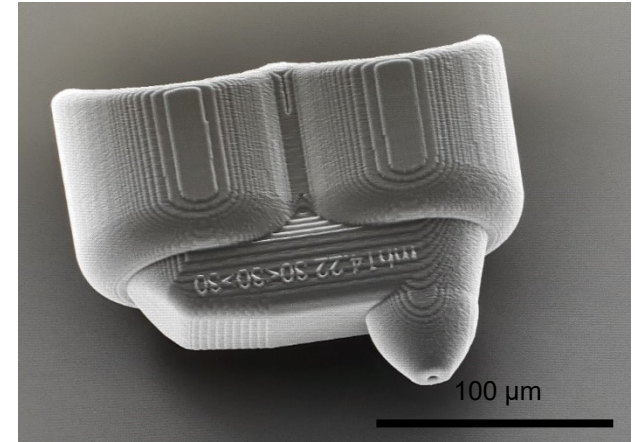
- GDVN or Microfluidic nozzels, flat sheets, Rayleigh Jets
 - ▶ Grinder
 - ▶ Plasma cleaner



<https://lcls.slac.stanford.edu/sed/equipment>

■ Nano 3D printer (SEC lab)

- Nanoscribe Photonic Professional GT2
 - ▶ Two-photon polymerization printing
 - ▶ Lateral feature sizes 160 nm
 - ▶ Printing area of up to 100 × 100 mm²



Sample injection

- Nozzle assembly
- Rapid prototyping
- Microfluidics

Nozzle fabrication Nano-3D printer

- Test sample injection
- Adjust concentration

Liquid-jet test-chamber Aerosol-jet test-chamber

Fast Solid Sample Scanner

Magnetic Fields

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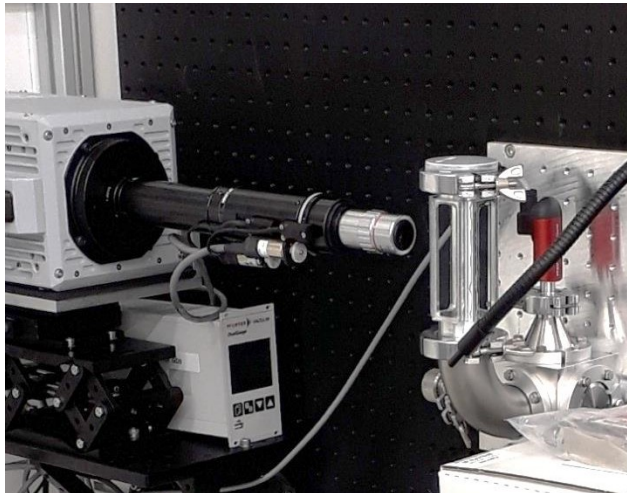
Liquid-jet test-chamber Aerosol-jet test-chamber

Fast Solid Sample Scanner

Magnetic Fields

■ Liquid-jet test chamber

- Test vacuum chamber
 - ▶ Fast camera
 - ▶ LED illumination
 - ▶ HPLC pump
 - ▶ Gas and liquid flowmeter

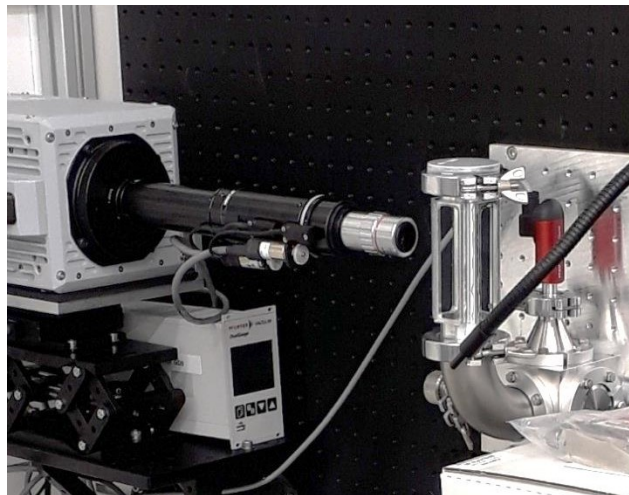


■ Nozzle fabrication

- GDVN or Microfluidic nozzels, flat sheets, Rayleigh Jets
 - ▶ Grinder
 - ▶ Plasma cleaner

■ Liquid-jet test chamber

- Test vacuum chamber
 - ▶ Fast camera
 - ▶ LED illumination
 - ▶ HPLC pump
 - ▶ Gas and liquid flowmeter

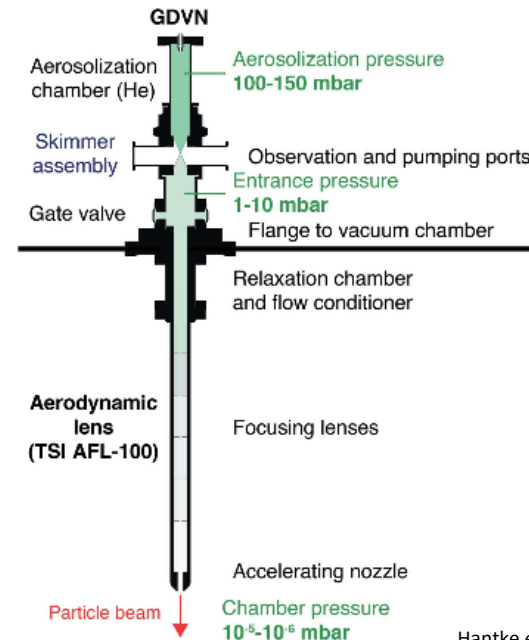


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- Nanoscribe Photonic Professional GT2
 - ▶ Two-photon polymerization printing
 - ▶ Lateral feature sizes 160 nm
 - ▶ Printing area of up to 100 × 100 mm²

■ Aerosol-jet test chamber

- “Uppsala injector”
 - ▶ GDVN
 - ▶ Aerodynamic lens
 - ▶ Rayleigh microscope



Sample injection

- Nozzle assembly
- Rapid prototyping
- Microfluidics

Nozzle fabrication
Nano-3D printer

- Test sample injection
- Adjust concentration

Liquid-jet test-chamber
Aerosol-jet test-chamber

Fast Solid Sample Scanner

Magnetic Fields

■ Nozzle fabrication

- GDVN or Microfluidic nozzels, flat sheets, Rayleigh Jets
 - ▶ Grinder
 - ▶ Plasma cleaner

■ Nano 3D printer (SEC lab)

- Nanoscribe Photonic Professional GT2
 - ▶ Two-photon polymerization printing
 - ▶ Lateral feature sizes 160 nm
 - ▶ Printing area of up to 100 × 100 mm²

■ Liquid-jet test chamber

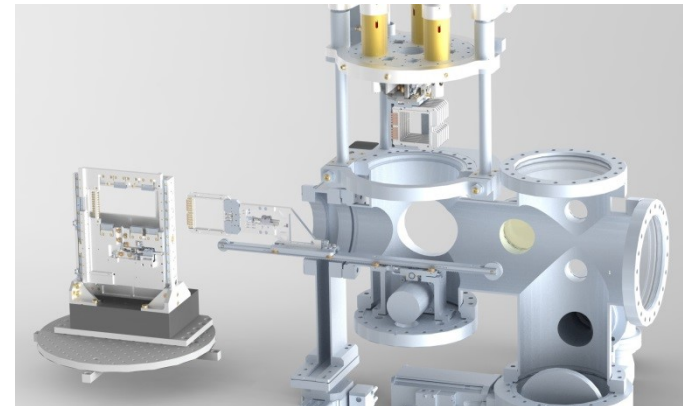
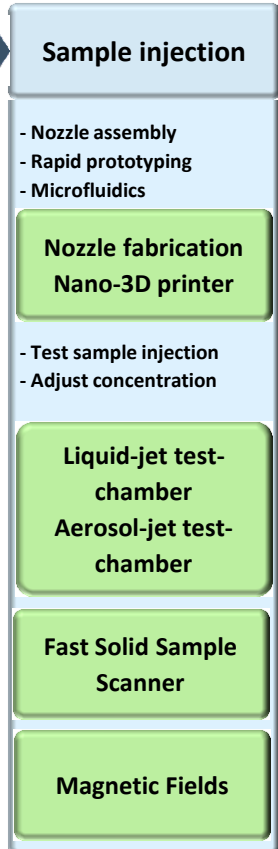
- Test vacuum chamber
 - ▶ Fast camera
 - ▶ LED illumination
 - ▶ HPLC pump
 - ▶ Gas and liquid flowmeter

■ Aerosol-jet test chamber

- “Uppsala injector”
 - ▶ GDVN
 - ▶ Aerodynamic lens
 - ▶ Rayleigh microscope

■ Fast Solid Sample Scanner

- SCS, MID and HED planned
 - ▶ Pre-characterization and localization
 - ▶ Load Lock with sample changer



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Liquid-jet test chamber

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Aerosol-jet test chamber

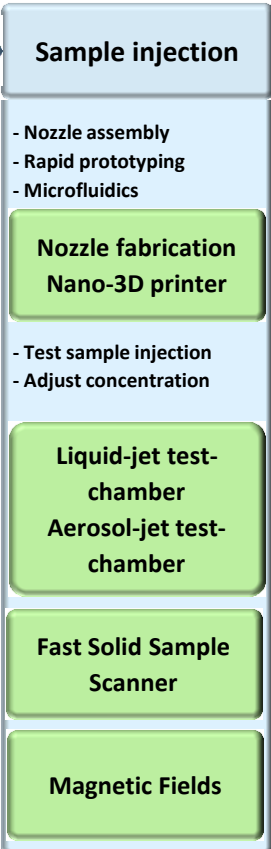
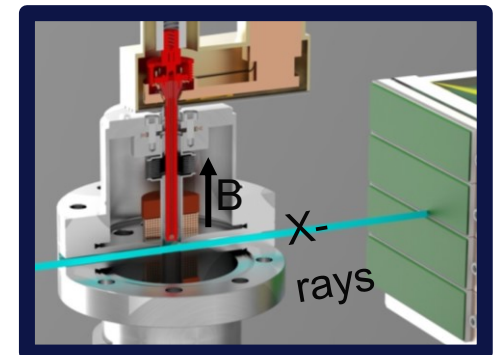
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Fast Solid Sample Scanner

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 - ▶ Pre-characterization and localization
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Magnetic Fields

- Home built miniature coils with cryostat



... moving science forward

- Providing knowledge and support for sample preparation
- Support users with sample testing and injection
- Develop new injection methods

- Help potential future users with sample characterization for beamline proposals
- Scientific collaboration projects
- Spread knowledge (schools, courses, workshops)

Acknowledgements



Sample Environment Group

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EMBL



UNIVERSITY
OF OULU



UPPSALA
UNIVERSITET



http://www.xfel.eu/call_for_proposals/